

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

Singer et al.

Serial No:

Not Yet Assigned

For:

ILLUMINATION SYSTEM WITH RASTER ELEMENTS OF

DIFFERENT SIZES

Filed:

Concurrently Herewith

Examiner:

Not Yet Assigned

Art Unit:

Not Yet Assigned

Docket No.: 637.0016USU

PRELIMINARY AMENDMENT

Box: Patent Application

Assistant Commissioner for Patents

Washington, D.C. 20231

Dear Sir:

Preliminary to examination, please amend the above-noted patent application as follows:

IN THE CLAIMS

Please amend the claims below to read as indicated herein. A version of the amended claims with markings to show changes made is included at the end of this document.

1. (Amended) An illumination system for lithography with wavelengths of ≤193 nm comprising:



a first optical element, which is divided into first raster elements and lies in a first plane, wherein said first plane defines an x-direction and a y-direction,